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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/673,873	09/30/2003	Sung-Bae Lee	SEC.1084	SEC.1084 2344	
20987	7590 07/27/2006	EXAMINER			
VOLENTINE FRANCOS, & WHITT PLLC ONE FREEDOM SQUARE			ESTRADA,	ESTRADA, MICHELLE	
11951 FREEDOM DRIVE SUITE 1260			ART UNIT	PAPER NUMBER	
RESTON, VA	A 20190		2823		

DATE MAILED: 07/27/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
Office Action Summary		10/673,873	LEE ET AL.				
		Examiner	Art Unit				
		Michelle Estrada	2823				
Period f	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1)⊠	Responsive to communication(s) filed on 09 Ma	av 2006					
	· · · · · · · · · · · · · · · · · · ·	action is non-final.					
3)							
ت ر	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
		ng in the application					
7)23	Claim(s) <u>6,23,25,28,32 and 35-48</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration.						
51⊠	Claim(s) <u>6,23,25,28 and 32</u> is/are allowed.						
	Claim(s) <u>0,23,25,26 <i>and</i> 32</u> is/are rejected.						
		niected to					
	Claim(s) 37,38,40,41,43,44 and 46-49 is/are objected to.Claim(s) are subject to restriction and/or election requirement.						
		cicolori requirement.					
Applicat	ion Papers						
9)☐ The specification is objected to by the Examiner.							
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.							
	Applicant may not request that any objection to the o	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11)	The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form P	TO-152.			
Priority	under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 							
Attachmen	• •	-					
	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948)	4) 🔲 Interview Summary Paper No(s)/Mail Da	(PTO-413) ite.				
3) 🔲 Infor	mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) or No(s)/Mail Date	5) Notice of Informal P. 6) Other:		O-152)			

DETAILED ACTION

Applicant's arguments with respect to claims 23, 35, 36, 39 and 42 have been considered but are moot in view of the new ground(s) of rejection.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 35, 36, 39, 42 and 45 are rejected under 35 U.S.C. 103(a) as being unpatentable over Blosse et al. (6,635,566) in view of Kim (6,576,947).

Blosse et al. disclose forming an insulation film (4) on a substrate (1); forming a photoresist pattern (5) on the insulation film; performing a first etching process comprising etching the insulation film through only part of its thickness using the photoresist pattern as a mask to form an initial trench in the insulation film (See fig. 2); subsequently removing the photoresist pattern (fig. 3); and subsequently performing a second etching process that widens the initial trench while maintaining the depth of the trench substantially the same as that of the initial trench (Fig. 6).

Blosse et al. does not disclose wherein said second etching process being distinct from said first etching process and comprising wet etching the insulation film.

Kim discloses a wet etching that enlarges the openings (312) as shown in figs 5A and 5B.

Art Unit: 2823

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Blosse et al. and Kim to enable the second etching step of Blosse et al. to be performed according to the teachings of Kim because one of ordinary skill in the art would have been motivated to look to alternative suitable methods of performing the disclosed second etching step of Blosse et al. and art recognized suitability for an intended purpose has been recognized to be motivation to combine. See MPEP 2144.07.

Re claims 36, 39 and 45, Blosse et al. disclose wherein said forming of the insulating film comprises forming one of an oxide film, a fluoride film and a nitride film on the substrate (Col. 5, lines 15-30).

Re claim 42, One of ordinary skill in the art would have been led to the recited etching rate through routine experimentation to achieve a desired etching rate. In addition, the selection of etching rate, its obvious because it is a matter of determining optimum process conditions by routine experimentation with a limited number of species of result effective variables. These claims are prima facie obvious without showing that the claimed ranges achieve unexpected results relative to the prior art range. In re Woodruff, 16 USPQ2d 1935, 1937 (Fed. Cir. 1990). See also In re Huang, 40 USPQ2d 1685, 1688 (Fed. Cir. 1996)(claimed ranges or a result effective variable, which do not overlap the prior art ranges, are unpatentable unless they produce a new and unexpected result which is different in kind and not merely in degree from the results of the prior art). See also In re Boesch, 205 USPQ 215 (CCPA) (discovery of optimum value of result effective variable in known process is ordinarily within skill or art) and In

re Aller, 105 USPQ 233 (CCPA 1995) (selection of optimum ranges within prior art general conditions is obvious).

Note that the specification contains no disclosure of either the critical nature of the claimed etching rate or any unexpected results arising therefrom. Where patentability is said to be based upon particular chosen etching rate or upon another variable recited in a claim, the Applicant must show that the chosen etching rate are critical. *In re Woodruf*, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

Allowable Subject Matter

Claims 6, 23, 25, 28 and 32 are allowed.

Claims 37, 38, 40, 41, 43, 44 and 46-49 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within

Page 5

TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michelle Estrada whose telephone number is 571-272-1858. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 571-272-2800.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

Application/Control Number: 10/673,873

Art Unit: 2823

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Michelle Estrada Primary Examiner Art Unit 2823 Page 6

ME July 17, 2006